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# TeraHertz HgTe nanocrystals: beyond confinement

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## Supporting Information Placeholder

**ABSTRACT:** We report the synthesis of nanocrystals with optical feature in the THz range. To do so, we develop a new synthetic procedure for the growth of HgTe, HgSe and HgS nanocrystals, with strong size tunability from 5 nm to 200 nm. This is used to tune the absorption of the nanocrystal all over the infrared range up to the teraHertz (from 2  $\mu\text{m}$  to 65  $\mu\text{m}$  for absorption peak and even 200  $\mu\text{m}$  for cut-off wavelength). The interest for this procedure is not limited to large size since for small objects we demonstrate low aggregation, good shape control (*i.e.* spherical object) while using non-expansive and simple mercury halogenide precursors. By integrating these nanocrystals into an electrolyte-gated transistor, we evidence a change of carrier density from p-doped to n-doped as the confinement is vanishing.

Colloidal quantum dots (CQD) have garnered significant scientific and technological interests because of their tunable optical features from ultraviolet (UV) to infrared (IR). While their photoluminescence appears as the first mass market application, CQD are actually as interesting for the design of low cost optoelectronic devices that combine the ease of processing of solution-processable material with the robustness of inorganic systems. This is especially true in the IR range where current technologies remain pricy. CQD offer an interesting platform, however reaching mid ( $\lambda > 3 \mu\text{m}$ ) and far infrared wavelength is challenging on a material perspective.<sup>1-3</sup>

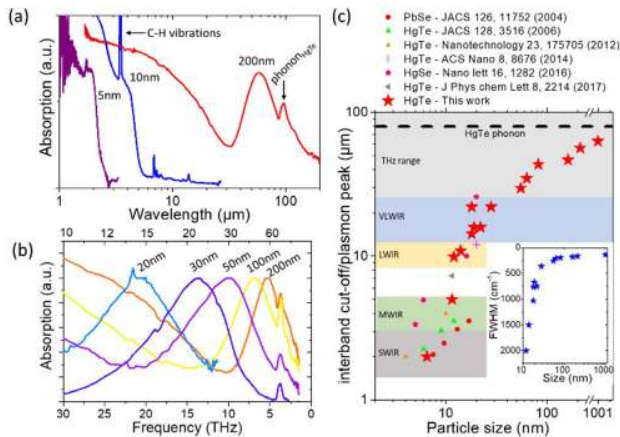
Only few materials can address absorption tunability up to the terahertz range: graphene<sup>4</sup>, doped semiconductors (Si, InSb)<sup>5,6</sup> and topological insulators such as Bi<sub>2</sub>Se<sub>3</sub><sup>7</sup>. However, the strong field localization of terahertz plasmon in a subwavelength volume makes that materials need to be designed in gratings. The wet chemical synthesis can be a potential alternative and easy way to produce terahertz materials. To reach this goal, the current synthetic procedures need to be pushed toward CQD-based terahertz technology. Mercury chalcogenides (HgX: HgS,<sup>8,9</sup> HgSe<sup>10-12</sup> and HgTe<sup>13</sup>) have reached the highest maturity to address this part of the electromagnetic spectrum because they combine mid-IR tunable optical features with photoconduction. Lots of effort have been made for the integration of HgX CQD, including the design of photoconductive<sup>14,15</sup>, photovoltaic,<sup>16</sup> phototransistor, devices<sup>17</sup>, plasmon assisted photodetection,<sup>18-20</sup> multicolor detection<sup>21,22</sup> and even hybrid with graphene<sup>23,24</sup>. A recent review on the field is given in ref<sup>25</sup>.

Among HgX, HgTe is the compound that leads to the best performances, with the lowest dark current and the fastest time response.<sup>25</sup> However, the current state of the art synthesis for mid-IR HgTe CQD relies on Keuleyan *et al.* synthesis and keep suffering from several limitations, which are discussed in more details in the supporting information.<sup>26,27</sup> In particular the material grows with an anisotropic shape (tetrapod or tetrahedron, see figure S1-S4) which tends to self-assemble into pairs (see figure S4) and leads to a loss of colloidal stability even for moderate size CQD. This is extremely detrimental to the design of pinhole free layer for vertical geometry device. Moreover, the final objects are strongly faceted and present the least reactive facet, which is limiting for growth of heterostructures. This perspective is even more challenging due to the high reactivity of mercury with chalcogenides. Consequently, nucleation and growth steps are difficult to be time-separated and low temperature growth is used in current synthesis (60-120°C), making the obtained material incompatible with usual high temperature (200-300°C) growth process of wide band gap colloidal material.<sup>8,28</sup> In term of shape control HgTe has not yet reached the maturity of CdSe. 2D HgTe platelets have recently been proposed by Izquierdo *et al.*<sup>29</sup> but they remain limited to the near-IR range. Shen *et al.*<sup>30</sup> have also proposed the use of a more reactive precursor such as bis-(trimethylsilyl)telluride (TMSTe) as a way to improve sphericity and aggregation. However, TMSTe is expensive and has a very limited stability, which prevents such synthesis to be viable at least at the industrial scale. Last, the current range of size spans from 3 to 20 nm, which makes that the obtained material is still strongly confined since HgTe presents a large exciton Bohr radius of 40 nm.<sup>31</sup> This prevents current material to address wavelengths above 12  $\mu\text{m}$ <sup>27,32</sup> and also limits the emergence of topologically protected states which are expected for poorly confined objects.<sup>33,34</sup>

In this paper, we report a new and simple synthetic procedure for the growth of HgTe CQD. We demonstrate size control from 5 nm to above 200 nm, which allows for the first time to cover the whole infrared range from 2  $\mu\text{m}$  up to the THz range (65  $\mu\text{m}$ ) with a single material. In particular, we focus on long wavelengths (10-100  $\mu\text{m}$  range), which are non-addressable based on previously reported synthesis. We also integrate these materials into electrolyte-gated transistors and demonstrate that HgTe CQD switch from p-type for the smallest size to n-type for the largest CQD.

To achieve a higher degree of control on HgTe CQD synthesis, we investigate for less reactive precursors. Our approach is based on the simultaneous injection of HgX<sub>2</sub> (with X=Cl, Br or I) and Te complexed with trioctylphosphine (TOP) in a hot solution of

oleylamine. It is worth noting that the procedure can be extended to the growth of HgSe and HgS (see figure S9 and S10), while using NaBH<sub>4</sub> reduced Se and elemental sulfur in oleylamine, respectively.



**Figure 1.** (a). absorption spectra of HgTe CQD with various sizes. (b) absorption spectra of HgTe CQD with various sizes, presenting a plasmonic feature in the LWIR, VLWIR or THz range. (c) Cut off wavelength of the interband transition (for material without plasmonic feature) and plasmonic peak wavelength (for doped material) as a function of the CQD size (diameter for spherical object). SWIR corresponds to Short-Wavelength Infrared range (1.5 to 3 μm), MWIR to Mid-Wavelength Infrared range (3 to 8 μm), LWIR to Long-Wavelength Infrared range (8 to 12 μm), and VLWIR to Very Long-Wavelength Infrared range (12 to 30 μm). Inset: full width at half maximum (FWHM) of intraband peak as function of CQD size.

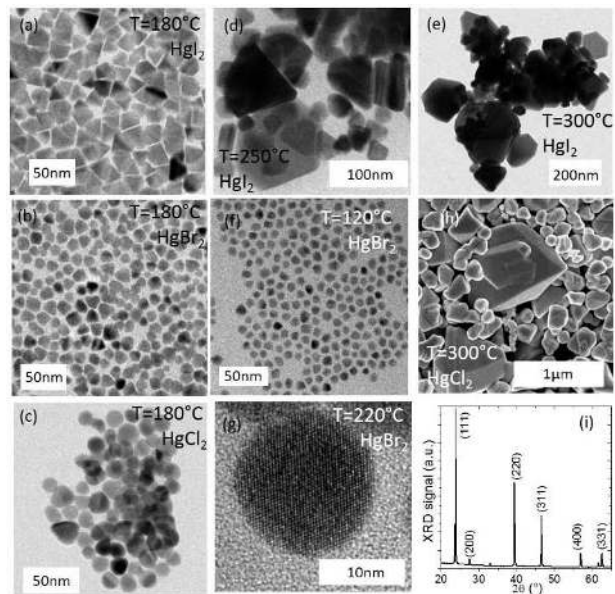
The size of the CQD is driven by three key parameters, which are temperature, the reaction time and the chosen mercury halide precursor. By tuning the reaction temperature from 120 °C up to 200 °C, the mean size of the CQD can be tuned from 5 nm up to 200 nm, see **Figure 1c**, 2 and Figure S5. Thus, it is possible to obtain absorption all over the infrared range from 2 μm up to 65 μm, see **Figure 1**. This approach presents the key advantages to both be able to synthesize small CQD sizes with sharp excitonic transition, but is also well suited to obtain large CQD, which are able to address long wavelength (>12 μm). **Figure 1b** shows how the Long-Wavelength Infrared range (LWIR, 8-12 μm range), Very Long-Wavelength Infrared range (VLWIR, 12-20 μm range) and THz (λ>30 μm) can be finely addressed using the developed protocol. The optical features have been pushed to an energy typically twice smaller than the previous record.<sup>10</sup>

In the case of large CQD, the spectrum is made of two components: an interband absorption at high energy and an intraband/plasmonic peak at low energy, see **Figure 1a** and **b**. The exact nature of the long wavelength feature actually depends on particle size and doping level.<sup>8</sup> The energy of this transition can be made low enough, so that the peak overlaps with the absorption resulting from the LO phonon line (at 123 cm<sup>-1</sup>). The Raman spectrum in figure S11 confirms the phonon character of this line. Another striking behavior is the exceptional narrowness of the intraband/plasmonic peak (< 200 cm<sup>-1</sup>) compared to what it can be for doped nanocrystals of Si<sup>35</sup> or oxides<sup>36-38</sup> (with a FWHM >1000 cm<sup>-1</sup>).

While the role of reaction time is rather trivial with an increase of the final size with time, the role of halide is more complex. We observe that chloride leads to larger objects compare to the other halides (>Br>I), see **Figure 2**. This trend is confirmed by following the absorption of the solution at 415 nm, which is the signature of

the amount of crystalline HgTe, see figure S5.<sup>32</sup> Even at low temperature (120 °C), the reaction is almost complete after 3 min in the case of HgCl<sub>2</sub>, while it is still unfinished after 3 h while using HgI<sub>2</sub>. As shown in Figure 2a, d and e, iodine precursor leads to more faceted objects. This may be attributed to the soft base character of iodine that allow a better bonding and poisoning surface made of soft acid mercury.<sup>39</sup>

As recently proposed by Shen et al.,<sup>30</sup> it is possible to tune the magnitude of the long wavelength peak of the absorption spectra while tuning the reaction stoichiometry. For moderate size CQD (12-40 nm), only the interband contribution is observed in the case of stoichiometric reaction (Hg:Te=1:1), while the long wavelength feature is obtained in Hg rich condition, see figure S8. Hg rich material tends to be n-type doped, which favor the observation of the intraband/plasmonic feature as observed for HgS and HgSe which are intrinsically n-doped.<sup>40</sup>



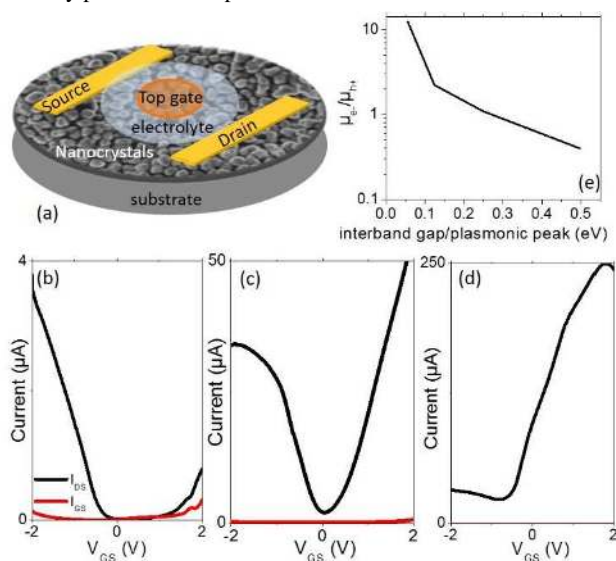
**Figure 2** (a), (b) and (c) are Transmission Electron Microscopy (TEM) images of HgTe CQD synthesized at 180°C with HgI<sub>2</sub>, HgBr<sub>2</sub> and HgCl<sub>2</sub> as Hg precursor, respectively. (d) and (e) are TEM images of HgTe CQD synthesized using HgI<sub>2</sub> as precursor at 250°C and 300°C, respectively. (f) and (g) are low and high resolution images of spherical HgTe CQD with limited aggregation. (h) is an Scanning Electron Microscopy (SEM) image of HgTe CQD synthesized at 300°C using HgCl<sub>2</sub> and (i) the corresponding X-ray diffractogram.

Transmission electron microscopy (TEM) images (**Figure 2**) clearly show a limited aggregation. Moreover, it is possible at low temperature to obtain almost nearly spherical objects, see **Figure 2** f and g. As shown in **Figure 2** d, e and h, the size dispersion is large for large objects. However, this is not critical since the plasmon linewidth of CQD is driven by the doping level rather than the confinement.<sup>8</sup> The crystalline nature of the obtained material is well revealed by high resolution TEM (**Figure 2** g) as well as by X-ray diffraction (**Figure 2** i). The diffraction pattern is consistent with the zinc-blende structure of HgTe.

To better highlight the role of doping on the optical properties, we integrate the film of HgTe CQD into electrolyte-gated transistor (see **Figure 3a** for a scheme of the device).<sup>41</sup> Such gating method is convenient because it combines low bias operation thanks to the large gate capacitance with air operability. As the nanoparticle size is increased, the material switches from p-type (conduction under hole injection) (**Figure 3b**) to ambipolar (**Figure 3c**) and finally to

n-type only (conduction under electron injection) for the largest sizes (**Figure 3d**). This change of behavior is further quantized by the increase of the ratio of electron mobility over hole mobility while the band gap is reduced, see **Figure 3e**.

This emergence of n-type conduction is similar to what has been observed for HgS<sup>8</sup> and HgSe<sup>10</sup> nanocrystals. Due to the combination of narrow band gap and high work function in HgX CQD, the material can be reduced by the environment.<sup>42</sup> This reduction however occurs for much larger size (*ie* lower confinement) because of the lower work function of HgTe material compared with HgS and HgSe.<sup>40</sup> This is interesting on an applied point of view because it preserves the gate effect even for large particles, while for other chalcogenides gate control is lost due to their too metallic character.<sup>43</sup> This means that even for the largest particle the number of carrier per particle remains in the range of what can be tuned by electrolyte gating (0-6 electrons typically). As a result, the long wavelength feature observed in the absorption spectra is probably not fully plasmonic and preserves an intraband character.



**Figure 3** (a) Scheme of an electrolyte gated transistor which channel is made of S<sup>2-</sup> capped HgTe CQD. Transfer curves (current as a function of gate bias) for HgTe CQD with an excitonic feature at 4000cm<sup>-1</sup> (b), a cut off at 2000cm<sup>-1</sup> (c) and a plasmonic feature at 450cm<sup>-1</sup> (d). (e) Variation of the ratio of the electron mobility over the hole mobility as a function of the interband gap.

In summary, we report a new synthetic procedure for HgTe nanocrystal, which allows an unprecedented tuning of nanocrystal sizes from small scale to far beyond the exciton Bohr radius. This leads to the first demonstration of colloidal nanocrystals with optical feature in the THz range. The synthesis is also promising for small size because of the low aggregation and good shape control (*ie* spherical objects) of the synthesized nanocrystals. Moreover, the synthesis relies on low reactivity precursor of mercury with low cost. The transport properties of the nanocrystals show a change of majority carrier density from p-type for small CQD to n-type for the largest object.

## ASSOCIATED CONTENT

### Supporting Information

The Supporting Information is available free of charge on the ACS Publications website.

Additional information includes experimental details on HgTe, HgSe and HgS nanocrystal synthesis, TEM pictures of HgTe CQD shape evolution with time and self-assembly in dimer, reactivity of different HgX precursors, absorption spectra with different stoichiometry of HgTe CQD, size distribution, experimental details on electron microscopies, UV-Vis, FTIR and Raman spectroscopies (PDF)

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### Notes

The authors declare no competing financial interests.

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